

# **License Application/Amendment Process**

## **Successes and Areas for Improvement**

Tammy S. Morin  
Holtec International  
June 23, 2010

# Topics



- Schedule
- Communications
- Content
- Guidance

# Schedule



- **Successes**
  - SFST is meeting review dates published in acceptance letters and review times shortened.
  - Use of Direct Final Rule for Part 72 Amendments.
  - Applicants meeting requested RAI response dates.
  - Applicants informing SFST of upcoming needs as input to their budget requests.
- **Areas of Improvement**
  - RAI response schedule can hinder ability for public meeting to ensure Staff's issues are addressed.
  - Communication of schedule expectations/progress after SER is submitted to rulemaking.

# Communications



- **Successes**
  - More public meetings informing Staff of applicant's licensing intentions.
  - Increased willingness for phone conversations to provide general information exchange.
- **Areas of Improvement**
  - Staff present at pre-submittal meetings not necessarily assigned as reviewers.
  - Need to familiarize Staff new to SFST with approved CoCs and their implementation.

# Content



- **Successes**
  - Issuance of NRC Acceptance Review Process
  - More complete applications with less editorial errors.
  - Thorough technical review as evidenced in the RAI.
- **Areas for Improvement**
  - Draft SER issued with RAI.
  - Formalizing the complete LAR Process.

- **Successes**
  - NRC in process of updating guidance documents.
  - NRC providing draft guidance for public comment.
- **Areas for Improvement**
  - Application of draft guidance documents in the current licensing reviews.
  - Uncertainties still exist with regard to level of detail required in the application as well as the required supporting documentation to be included.

# Summary



- Increase communication and general information transfer.
- Continue processes which add value and add new processes as necessary.
- Establish consistent practices in-line with regularly updated guidance.